



JFW

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of:

HAYASHI et al.

Art Unit: 1725

Application No.: 10/622,490

Examiner: Maria A. Elve

Filed: July 21, 2003

Attorney Dkt. No.: 59556.00006

For: MARKING METHOD AND MAKING APPARATUS USING MULTIPLE
PHOTON ABSORPTION, MARKED OPTICAL ELEMENT MANUFACTURED BY
USING THE MARKING METHOD AND THE MARKING APPARATUS

RESPONSE UNDER 37 CFR § 1.111

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

March 21, 2005

Sir:

In response to the Office Action dated December 20, 2004, please consider the
remarks as set forth below.

Amendments to the Specification are submitted on page 2.

Remarks are submitted on page 3.